Preparation and Microstructure of a ZrB₂–SiC Composite Fabricated by the Spark Plasma Sintering-Reactive Synthesis (SPS-RS) Method

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A mixture of Zr, B₄C, and Si powders was adopted to synthesize a ZrB₂-SiC composite using the spark plasma sintering-reactive synthesis (SPS-RS) method. SPS treatments were carried out in the temperature range of 1350°-1500°C under a varying pressure of 20-65 MPa with a 3-min holding time. A dense (~98.5%) ZrB₂-SiC composite was successfully fabricated at 1450°C for 3 min under 30 MPa. The microstructure of the composite was investigated. The in situ formed ZrB₂ and SiC phases dispersed homogeneously on the whole. The grain size of ZrB_2 and SiC was <5 and $1\mu m$, respectively. A number of in situ formed ultrafine SiC particles were observed entrapped in the ZrB₂ grains.

I. Introduction

PREVIOUS studies have shown that composites of ZrB_2 with SiC are conditioned in the state of ZrB_2 with SiC are candidates for ultra high-temperature applications. The addition of SiC can improve the oxidation resistance and may inhibit grain growth and improve strength.^{1,2} Several methods have been utilized for the preparation of dense ZrB2-SiC composites. For example, ZrB2-SiC composites could be produced by hot pressing (HP) of mechanically mixed powders. Sometimes, ceramic additives are used to enhance the sinter-ability. The sintering temperature is typically above $1800^{\circ}C^{3,4}$ Reactive hot pressing (RHP) is an alternative route to fabricate ceramic composites, and some attempts to synthesize ZrB2-SiC composites have been made by RHP. ZrB2-20 vol% SiC composites with a relative density in excess of 95% have been successfully fabricated at 1650°C by RHP.⁵⁻⁸ Compared with HP, RHP could synthesize ZrB₂-based composites at a relatively low temperature without sintering aids, while in the abovementioned methods, the typical duration of cycles is more than 2 h and the sintering temperature is above 1650°C.

Recently, we reported a simple one-step method, that is, a spark plasma sintering-reactive synthesis (SPS-RS) method. This novel fabrication process combines the advantages of an in situ process and an SPS process. In our previous work, dense composites such as Ti₅Si₃-TiC-Ti₃SiC₂, Ti₅Si₃-TiC, and Ti₃-SiC₂-SiC with fine microstructures were successfully fabricated in about 20 min, and the sintering temperatures were 100°-200°C lower than that of RHP.9-11

Based on the above research, we used this new technique to synthesize a ZrB₂-SiC composite with Zr, Si, and B₄C as the starting powders. In this communication, the manufacturing

process, microstructure, and mechanical properties of the composite are reported.

II. Experimental Procedure

The starting powders were Zr (purity 95.82%, impurities include Ti 2.34, Hf 0.52, Fe 0.24, W 0.08, Cr 0.06, particle size <45 μm, Guoyao Chemicals Co. Ltd., Shanghai, China), Si (purity >99%, particle size <50 µm, Guoyao Chemicals Co. Ltd.), and B₄C (purity 99%, particle size about 2 µm, Jingangzhuan Boron Carbide Co. Ltd., Mudanjiang, China). Si was milled in an agate jar using absolute ethanol and agate balls beforehand. After being milled for 48 h, the particle size decreased to about 2 μm, as determined by scanning electron microscopy (SEM). The stoichiometic powders were ball milled in ethanol with ZrO₂ balls for 24 h, and then dried. The mixed powders were placed in a graphite die (15 mm in diameter) and sintered with the Dr. Sinter[®] 2040 spark plasma sintering system (Sumitomo Coal Mining Co., Tokyo, Japan) in vacuum (<6 Pa). The heating rate was controlled to about 80°C/min and the pressure was applied from 1250°C and maintained constant during the subsequent heating and holding period. The experiments were carried out in the temperature range of 1350°-1500°C under various pressures of 20-65 MPa for 3 min. The current was stopped and pressure was released as soon as the holding at the sintering temperature was over. The whole process took only 20-22 min.

After sintering, the surfaces of the samples were ground to remove the graphite layer. The bulk density was measured using the Archimedes method. According to reaction (1), the volume percents of ZrB₂ and SiC in the composite obtained are 74.85% and 25.15%, respectively. The theoretical density of the composite calculated according to the rule of mixtures is 5.37 g/cm^3 , based on the densities of 6.09 and 3.21 g/cm³ for ZrB_2 and SiC, respectively,

$$2Zr + Si + B_4C \rightarrow 2ZrB_2 + SiC \tag{1}$$

Phase composition was determined by X-ray diffraction (XRD; D/Max-2250V, Rigaku, Tokyo, Japan) using CuKa radiation. The microstructure analyses of the samples were conducted using SEM (JXA-8100, JEOL, Tokyo, Japan). Vickers hardness (H_v) of the polished samples was measured by the indentation technique (Wilson-wolpert Tukon[®] 2100B, Instron, Boston, MA). The indentation parameters were made using a 10-kg load with a dwell of 15 s.

III. Results and Discussion

Figure 1 shows the XRD results of the raw powder and the samples sintered at different temperatures. From the XRD patterns, it appears that some ZrB₂ had formed at 900°C, but that SiC formation was not detected until 1000°C. Within the

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Fig. 1. X-ray diffractometry patterns of the $Zr/Si/B_4C$ mixed powders heated at (b) 900°C, (c) 1000°C, (d) 1200°C, and (e) 1500°C.

temperature range 900°–1200°C, several chemical reactions take place. The emergence of intermediate phases such as ZrC and the mixture of zirconium silicides, most probably Zr_2Si and $ZrSi_2$, were ascertained.

In order to fabricate a composite with nearly fully dense composites, a much higher sintering temperature and pressure are needed, although reaction (1) is completed at 1200°C. According to Fig. 2, the relative densities of all samples increase with increasing pressure, but the trend is lowered with increasing temperature. A dense (~98.5%) ZrB₂–SiC composite could be fabricated at 1450°C under 30 MPa for 3 min. Although the relative density is considerably high, it is believed that the relative density can be improved through further optimization of the processing parameters. Compared with HP and RHP, a ZrB₂–SiC composite could be fabricated via SPS–RS at a relatively low temperature and a short time, and so we believe that the SPS–RS technique is considerably advantageous in the synthesis of a ZrB₂–SiC composite.

The microstructure of a composite synthesized at 1450° C under 30 MPa is shown in Fig. 3. On the whole, the distribution of the *in situ* formed ZrB₂ and SiC phases was homogeneous, although agglomeration existed. The phase distribution is related to the particle size of the staring powders, in agreement with



Fig. 2. Variation of relative density depending on the sintering temperature and pressure.



Fig. 3. Backscattered electron image of a polished surface of the as-sintered composite (the gray phase represents ZrB_2 , and the dark phase represents SiC).

that reported for a $ZrB_2\mathcal{--}25$ vol% SiC composite synthesized by RHP. 5,6

Figure 4 shows the SEM micrograph from a fracture surface of this sample. The grain size of ZrB_2 and SiC is < 5 and 1ím, respectively. Usually, the grain size depends on the sintering temperature, and the average grain size increases with the sintering temperature. HP of ZrB_2 -SiC composites is typically conducted above 1800°C, and RHP needs a temperature above 1650°C. The SPS–RS process in this work is conducted at a markedly lower temperature with a shorter holding time. In addition, can easily be seen from Fig. 4 that the fracture mode is mainly intragranular.

Both intergranular and intragranular SiC grains are found in the micrographs of the composite, and a number of SiC grains (<0.5 µm) are entrapped within the ZrB₂ grains. The reason for the formation of this microstructure was possibly based on the following two factors: (i) some of the SiC grains may not form directly from the initial Si, but from intermediate phases. By analogy with a similar system,¹² the following chemical reactions (*dG*₂₅: Gibbs-free energy of reaction at 25°C) are proposed to occur.

$$3Zr + B_4C = 2ZrB_2 + ZrC (dG_{25} = -759 kJ/mol)$$
 (2)

$$x\mathbf{Z}\mathbf{r} + y\mathbf{S}\mathbf{i} = \mathbf{Z}\mathbf{r}_x\mathbf{S}\mathbf{i}_y, \ x/y = 1/2, 2$$
(3)

$$2ZrC + 3Si + B_4C = 2ZrB_2 + 3SiC (dG_{25} = -391 \text{ kJ/mol})$$
(4)



Fig. 4. Scanning electron micrograph from a fracture of the as-sintered composite (examples of intragranular SiC particulates are marked with black arrows).

$$ZrSi_2 + B_4C + ZrC = 2ZrB_2 + 2SiC (dG_{25} = -356 kJ/mol)$$
 (5)

$$Zr_2Si + B_4C = 2ZrB_2 + SiC (dG_{25} = -427 kJ/mol)$$
 (6)

$$ZrSi_{2} + Zr_{2}Si + 3B_{4}C + 3Zr = 6ZrB_{2} + 3SiC$$

(dG₂₅ = -1541 kJ/mol) (7)

Reactions (5)–(7) describe the delayed formation of SiC. (ii) the shortened sintering time and lowered sintering temperature, as a high sintering temperature and a long sintering time, could induce grain growth. With lowered sintering temperature and a shortened sintering time, the SiC nanophase can be retained. It is speculated that the reaction nucleation and grain growth rate of ZrB₂ is much faster than that of SiC. During sintering and consolidation processes, some of the SiC grains (<0.5 μ m) remain located intragranularly. A similar structure was reported in a study of the beneficial effects of an ultrafine SiC on the sinterability and mechanical properties of ZrB₂.¹³ The mechanism of this interesting structure formation needs to be further investigated.

The characteristics of the composite synthesized at 1450°C under 30 MPa were measured. The fracture toughness (K_{Ic}) value was 4.31 ± 0.20 MPa · m^{1/2}. For the composites of ZrB₂ with 20–30 vol% SiC prepared by HP and RHP, the fracture toughness values range from 3.9 to 5.5 MPa · m^{1/2}.^{2,4,5,13,14} The Vickers hardness (H_v 10) of the composite was 17.18±0.26 GPa, compared with the hardness of 17.5–27 GPa reported by other authors, which is not high. The inhomogeneous distribution of SiC might result in a relatively low hardness.

IV. Conclusions

A combined SPS–RS approach was used to prepare a ZrB_2-25 vol% SiC composite using Zr, B₄C, and Si as the reactants. A dense (~98.5%) composite was obtained at 1450°C for a 3-min dwelling time under 30 MPa. The entire processing time applied to obtain a nearly full density through this method was much shorter (about 20–22 min) than that necessary for the HP or

RHP. The microstructure was fine and homogeneous on the whole. The grain size of ZrB_2 was $<5 \mu m$, and that of SiC was $<1 \mu m$. The Vickers hardness was 17.18 ± 0.26 GPa, and the fracture toughness was 4.31 ± 0.20 MPa $\cdot m^{1/2}$. The intrafracture mode dominated the fracture process.

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